M odulation of the Curie Tem perature in Ferrom agnetic/Ferroelectric Hybrid Double Quantum Wells

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A bstract

We propose a ferrom agnetic/ferroelectric hybrid double quantum well structure, and present an investigation of the Curie temperature (T_c) modulation in this quantum structure. The combined electric elds and spontaneous electric polarization are considered for a system that consists of a Mn -doped well, a barrier, and a p-type ferroelectric well. We calculate the change in the envelope functions of carriers at the lowest energy subband, resulting from applied electric elds and switching the dipole polarization. By reversing the depolarizing eld, we can achieve two different ferrom agnetic transition temperatures of the ferrom agnetic quantum well in a xed applied electric eld. The Curie temperature strongly depends on the position of the Mn -doped layer and the polarization strength of the ferroelectric well.

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The diluted magnetic semiconductor (DMS) has been generally known as one of the promising candidates for spintronic device materials in virtue of the coexistence of ferromagnetic and semiconducting properties in it. Ferroelectric material has also attracted signicant interest because of its promising potential in various technological applications, such as binary data storage media in nonvolatile random access memories due to its spontaneous electric polarization. In both research elds, many experimental and theoretical studies have been performed.

Because the spintronic devices should ultim ately be operated at room temperature, much e orthas been focused on increasing the ferrom agnetic transition temperature (T_c) of DMS above room temperature. Among many materials, ZnMnO is considered to have T_c above 300 K with 5% Mn per unit cell and 3 10^{20} holes per cm³ according to a theoretical prediction.[1]

Recently, observation of the ferroelectric properties was reported in Li-doped ZnO bulk samples.[2, 3] The reason for the ferroelectric property is attributed to the following: when the size of the dopant Li atom (0.6 A) is smaller than the host Zn atom (0.74 A)[2], then the Li atom s can occupy o -center positions, thus locally inducing electric dipoles, thereby leading to ferroelectric behavior like PbG eTe[4] ferroelectric sem iconductor (FES).

The mechanism of DMS ferrom agnetism is classi ed upon materials and growing techniques. The rst class of approach is ferrom agnetism due to the Ruderm an-Kittel-Kasuya-Yoshida (RKKY)/Zener indirect exchange interaction by delocalized holes (hole mediated) based on the mean-eld approximation. [5, 6] The second class of approach is also carrier-induced ferrom agnetism as a results of KKR-CPA-LDA (Korringa-Kohn-Rostoker coherent-potential approximation and local density approximation) calculations of the electronic structure of doped DMS alloys. [7, 8] The third class of approach suggests the hole hopping mediated ferrom agnetism between polarons having strongly localized charge carriers. [9, 10] And the fourth one is ferrom agnetism due to the ferrom agnetic clusters or secondary phases. [11, 12] Therefore, it is necessary to decide on a case-by-case basis which mechanism is applicable. In our work, we apply the rst class of approach based on the mean-eld theory for carrier-induced ferrom agnetism in a DMS. [13, 14, 15]

Using ideas based on the dependence of T_c of DMS on the spatial distribution of magnetic ions, and envelope functions of carriers at the lowest energy subband in a conning potential [15, 16, 17], we model a hybrid double quantum well (HDQW) system shown in Fig.

1(a). The structure of ZnO /Zn₁ x M g_xO /Zn₁ y Li_yO has the upper p-type ZnO well with an additional M n —doped layer at the middle of the well (or at the upper edge of the well). The p-type might be achieved by the doping of group V [18, 19] or group I[20] elements. The lower well Zn₁ y Li_yO is the p-type ferroelectric well with spontaneous polarization P. The inverse potential prole of a hole is shown in Fig. 1(b), for dipole up and dipole down cases respectively. Because screening lengths at the interfaces between ZnLiO and ZnM gO are assumed to be dimension of the structure are chosen: W₁ = 10 nm, W₂ = 10 nm, B=5 nm, and the capping layer is 20 nm. The conmement potential is V₀=-263 meV with 20% of M g per unit cell in ZnM gO barriers.[21] Because our work is applicable in a regime of low carrier density, occupying only the lowest energy subband of a heavy hole, carrier concentrations of both wells are in the order of 10^{11} /cm ² [15] and the additional band bending due to carriers is small.[22]

We previously demonstrated electric eld control of ferrom agnetism in M n -doped asymmetric conventional double quantum wells (CDQW) [14], but present structure is dierent from CDQW because of hybridizing ferroelectricity. In this work, we can obtain additional electric well due to the reversal of spontaneous depolarizing elds. We can control the number of holes around the M n -doped layer by reversing depolarizing elds as well as applying electric elds. The main purpose of this work is to show the possibility of using ferrom agnetic ferroelectric hybrid structures to modulate $T_{\rm c}$ by reversing polarization. We can obtain two dierent ferrom agnetic transition temperatures in the same applied electric eld in HDQW.

The Hamiltonian for this system is given by

$$H = \theta_z \frac{1}{m^0(z)} \theta_z + V_c(z) \quad F_g z + V_d(z) :$$
 (1)

Throughout this calculation, we adopt atom ic units $R = m_0 e^4 = 2 \, h^2$ for the energy unit, and $a_B = h^2 = m_0 e^2$ for the length unit, where m_0 is the free electron mass. Here $m_0 = m_0 = m_0$ and m is the hole electrice mass and F_g is the carrier charge times for the applied electrice elds. V_d is the potential due to the spontaneous depolarizing eld. Because we would like to provide a qualitative estimation without complication, we ignore the Hartree and exchange-correlation interactions among carriers, and self-consistent solving of electrostatic potential with the Poisson equation even though the Hartree and exchange-correlation interactions

are related to the e ective mass[22] and distribution of carrier spins.[23] The thickness of the barrier is enough so that we can ignore coupling by tunneling between the wells. We attempt to solve the eigenvalue problem, H (z) = E (z), and it becomes

$$\frac{1}{m^0} \theta_z^2 \quad (z) \quad [V_c(z) \quad F_g z + V_d(z) \quad E] \quad (z) = 0;$$
 (2)

The carrier con nement potential $V_c(z)$ is V_0 inside the wells and 0 outside the wells. The potential due to dipoles is $V_d(z) = F_d(z) + (V_0 V_1)$ where $F_d(z)$ is the spontaneous depolarizing eld and $V_1(z) = 0$ is the electrostatic potential at the interface due to screening charges [24] by the Thomas-Fermimodel of screening. signs correspond to dipole left and dipole right cases. This potential profile is shown in Fig. 1 (b) with $F_g = 0$. We know that the general solution for Eq. (2) is a linear combination of A iry functions, A i(x) and B i(x). Thus, we write

$$(z) = C_1 A i() + C_2 B i();$$
 (3)

w here

=
$$(m^0 \mathcal{F}_g + \mathcal{F}_d)^{1=3} \left[z - \frac{E - V_0 - V_1 + \mathcal{F}_d \frac{B}{2}}{(\mathcal{F}_g + \mathcal{F}_d)} \right]$$
:

with = $Sgn(F_g + F_d)$ for the region W 2 and

$$= (m^{0}F_{g})^{1=3} [z - \frac{V_{c} E}{F_{g}}];$$

for elsewhere with $F_g > 0$ assumed. By using boundary conditions and the continuity of wave functions and their derivatives at the boundaries of each region, we can calculate C_1 and C_2 and energy eigenvalues in the system numerically. In principle, we should include the elects of the exchange interaction between M n ions and carriers on the carrier wave functions[6, 25], but we ignore these elects because our system has only a very thin M n -doped layer. Therefore, our wave function is limited to a system with very thin M n layers (submonolayer).[26] We write T_c in the form [13, 15]

$$T_{c} = \frac{S (S + 1)J_{pd}^{2}}{12k_{R}} \frac{m}{h^{2}} dz j (z) j^{4} c(z)$$
 (4)

Here, c(z) is a magnetic ion distribution function, J_{pd} is the exchange integral of carrier-spin exchange interaction, and S is a M n ion spin. We calculate the change in the fourth power

of growth direction envelope functions, j (z) $\frac{1}{2}$, of carriers at the lowest energy subband in the HDQW as a function of the applied electric elds.

In numerical calculations, we choose physical parameters for p-type ${\rm ZnO}/{\rm Zn_{1~x}}\,{\rm M}\,{\rm g_{x}O}/{\rm Zn_{1~y}}\,{\rm Li_{y}O}$, with ${\rm x}=0.2$ and ${\rm y}=0.05$ The connement potential ${\rm V_{0}}=263\,{\rm m\,eV}$, and ${\rm m_{h}^{0}}=0.78$ and 1 for the well and the barrier, respectively.[21, 27] In our calculation, the exact values of ${\rm J_{pd}}$ and S are not required because we calculate the ratio of ${\rm T_{c}}$ in Eq. (4). Usually ${\rm J_{pd}}$ is one of the important factors in determining the size of ${\rm T_{c}}$.

Figure 2 (a) shows the dependence of the ratio of ferrom agnetic transition temperatures, $T_c=T_{c0}$, on bias voltage applied across the dipole left HDQW , for Mn center-doped (open triangle), and Mn edge-doped (closed circle) respectively. Here T_{c0} is T_c at $F_g=0$ meV/nm for the Mn center-doped CDQW without Lidoping.[14] For $Zn_{0.95}Li_{0.05}O$, there are approximately 1.05 dipoles/nm³, and they induce a maximum polarization of approximately 8.77 C/cm². While there is no depolarizing eld (a full screening case) when barriers are metal, the maximum depolarizing eld can be up to 1.2 eV/nm [28] when barriers are insulators (no screening charge). Our case is in between those cases, the depolarizing eld $F_d=0.01$ meV/nm and the screening electrostatic potential $V_1=0.02$ meV are used as input parameters for dipole down FES. Applied electric elds shift the envelope functions according to the change of potentials, as shown in Fig. 2 (b). Then, the electric hole concentration increases (decreases) in the Mn edge-doped layer (center-doped), and T_c increases (decreases) as a result. When F_g is less than 2 meV, there are few carriers connect at the lowest subband of the Mn doped well because of the electror frequency.

Figure 3 shows the dependence of the ratio of ferrom agnetic transition temperatures $T_c = T_{c0}$ on bias voltage applied across the M n center-doped HDQW for dipole down (closed circle), and dipole up (open triangle) respectively. By reversing the direction of spontaneous polarization, the change in C urie temperature occurs below $F_g = 2 \, \text{m eV}$. This elect is caused by asymmetry of electrostatic potential due to screening charges. The larger asymmetry is, the more electrostatic potential due to screening charges. The larger asymmetry is, asymmetric potential to obtain this result. Both dipole down and dipole up cases have the same value of $T_c = T_{c0}$ above $F_g = 2 \, \text{m eV}$, because the envelope functions of carriers depend on the potential profile of the M n doped well (left side well), which are not a lected by F_a as shown in the inset. When the coercive eld of the ferroelectric well is much smaller than

the $F_g=2\,\mathrm{m}\,\mathrm{eV}$, the Curie tem perature m ay change at the coercive eld. But we do not take the reversal of polarization due to F_g into account, because we are interested in the regime of F_g lower than the coercive eld. The inset shows the change in the potential prole due to the reversal of dipole polarization in the HDQW as a function of z at $F_g=4\,\mathrm{m}\,\mathrm{eV}/\mathrm{nm}$. The potential proles in the left-hand side well are the same regardless of the direction of dipoles. The energies of the lowest subbands are the same. These energy eigenvalues are shown in Fig. 4.

Figure 4 shows energy eigenvalues as a function of applied electric elds for HDQW . Solid lines indicate the upper energy lim it of the Mn delta-doped well. The energy degeneracy occurs at $F_g=0$ for CDQW . When we compare the dipole right case and dipole left case of Fig. 4, the energy degeneracy at $F_g=0$ shifts to the left (dipole right) or to the right (dipole left), because the energy levels corresponding to the Mn doped well are the same, and only the energy levels of the FES well are shifted up (dipole right) or down (dipole left) by the depolarizing eld. Therefore, the lowest subband transition occurs in the dipole left FES well case in Fig. 4 (b). It causes the abrupt increase of $T_c=T_{c0}$ in Fig. 3.

Figure 5 shows the e ect of the depolarized eld strength on the dependence of the ratio of ferrom agnetic transition temperatures $T_c = T_{c0}$. We display three dierent depolarized eld and apply the bias voltage across the M nedge-doped and dipole left HDQW. As we expected, they have dierent transition points depending on the F_d values. All three lines merge into one because the potential proles of the Mn doped well are not a ected by F_d , as in Fig. 3.

In conclusion, we have proposed the DM S/FES hybrid double quantum well structure. By using the e ects of the spontaneous depolarizing eld from the FES well, we can modulate the ferrom agnetic transition temperature of the DMS well in this system. We calculate the Curie ferrom agnetic transition temperature in terms of its dependence on the envelope functions of carriers at the lowest energy subband. Through the reversal of the depolarizing eld, we obtain two dierent ferrom agnetic transition temperatures in an applied electric eld. This result opens the possibility of using ferrom agnetic/ferroelectric hybrid quantum structures for future multinary spin devices.

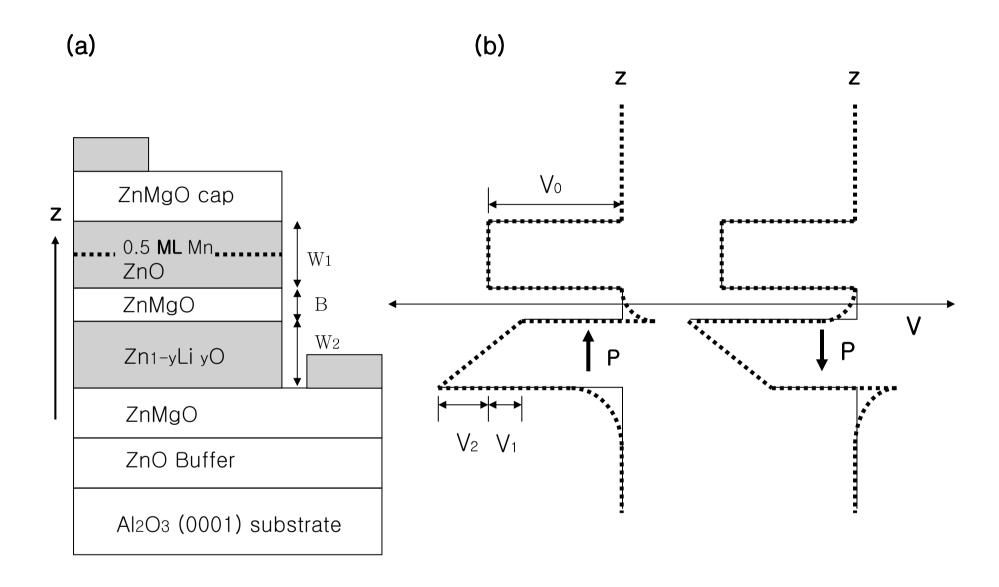
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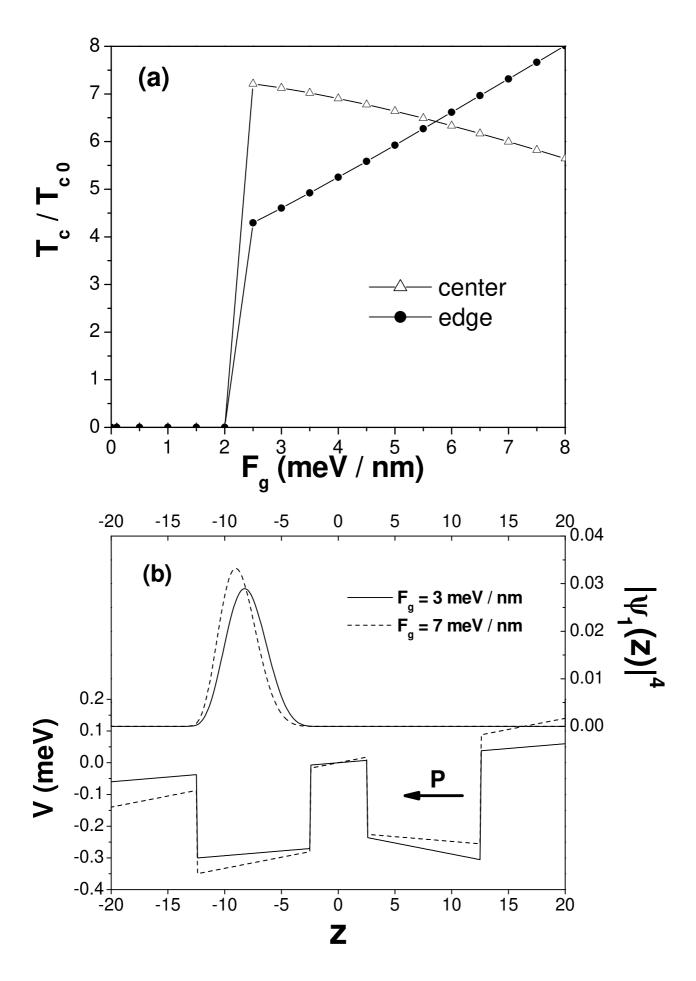
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- [28] Ref. [2]says that the spontaneous polarization and the coercive eld (E_c) are reported as 0.044 c/cm 2 and 2 kV/cm in bulk ($Zn_{0.83}Li_{0.17}$)O . Here we use the possible values by theoretical calculation.

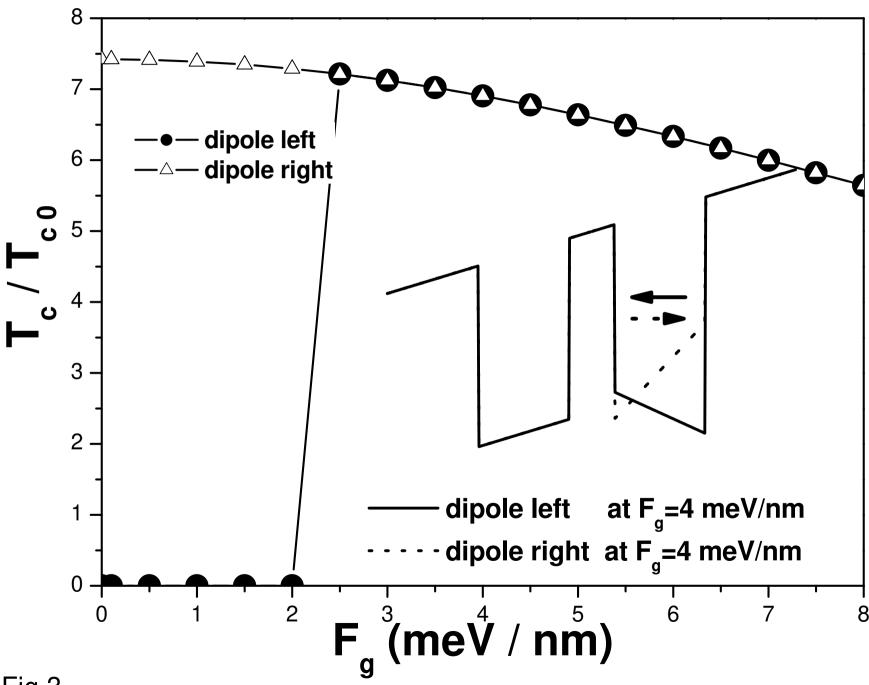
- FIG. 1: (a) Schem atic diagram of DM S/FES hybrid double quantum wells. The upper well has a $0.5\,\mathrm{m}$ onolayer of M n —doped layer at the m iddle of the well (or at the upper edge of the well). The lower well is Li-doped ZnO with spontaneous electric polarization. (b) The potential prole of the HDQW structures (dotted line) for a dipole up (left) and dipole down (right) cases is shown. The connem ent potential is $V_0 = 263\,\mathrm{m}\,\mathrm{eV}$ with 20% of Mg per unit cell in ZnM gO barriers. V_1 and V_2 are electrostatic potential due to screening charges at the interfaces.
- FIG. 2: (a) Dependence of the ratio of ferrom agnetic transition temperatures T_c/T_{c0} on bias voltage applied across the dipole left HDQW for Mn center-doped (open triangle) and Mn edgedoped (closed circle) respectively. The system size is $W_1 = 10 \text{ nm}$, $W_2 = 10 \text{ nm}$, B = 5 nm. Here T_{c0} is T_c at $F_g = 0 \text{ m eV/nm}$ for the Mn center-doped conventional DQW without Lidoping. (b) Change in the fourth power of the growth direction envelope functions of carriers at the lowest energy subband (upper panel), and the potential prole (lower panel) in the HDQW as a function of z at $F_g = 3 \text{ m eV/nm}$ (solid) and 7 m eV/nm (dashed).
- FIG. 3: Dependence of the ratio of ferrom agnetic transition tem peratures T_c/T_{c0} on bias voltage applied across the M n center-doped HDQW for dipole left (closed circle) and dipole right (open triangle) respectively. Inset shows the change of the potential prole due to the reversal of dipole polarization in the HDQW as a function of z at $F_g = 4$ m eV/nm.
- FIG. 4: Energy eigenvalues as a function of applied electric elds for hybrid double quantum wells for (a) dipole right and (b) dipole left cases. Solid lines indicates the energy upper lim it of M n delta-doped well.
- FIG. 5: Dependence of the ratio of ferrom agnetic transition tem peratures T_c/T_{c0} on bias voltage applied across the M n edge-doped and dipole left HDQW for di erent depolarized electric elds.



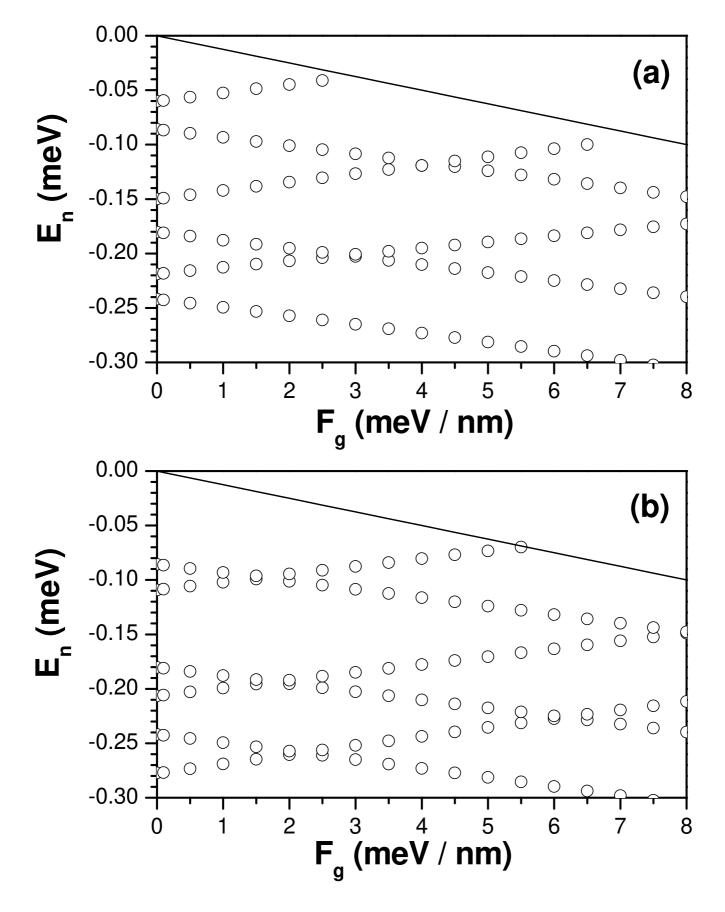
Kim-Fig. 1



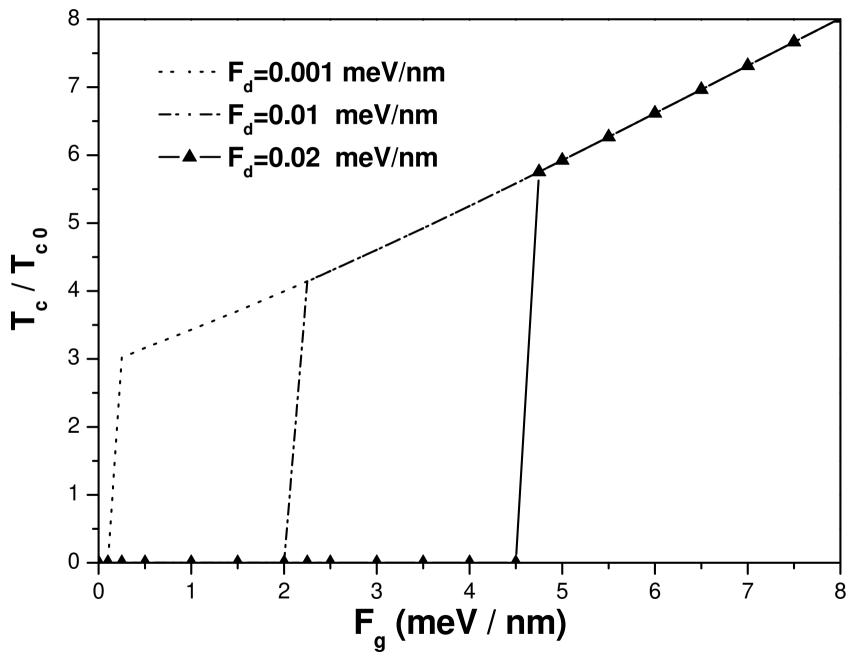
Kim-Fig. 2



Kim-Fig.3



Kim-Fig. 4



Kim-Fig. 5